- 3:40 F-45 SRM 2855 ADDITIVE ELEMENTS IN POLYETHYLENE WDXRF ANALYSES AND CERTIFICATION APPROACH J.R. Sieber, National Institute of Standards and Technology, Gaithersburg, MD
- 4:00 F-43 OXIDIC CALIBRATION USING WDXRF-MULTISCAT®: APPLICATIONS SHOWN FOR MINERALS, ORE CONCENTRATES AND SLAGS
 S. Bäckman, I. Bernhardsson, XRF Analytical AB, Sweden
- 4:20 F-31 Classes of Materials (COM)—A Tool for Analysis and Material Identification

J. Kessler, V. Roßiger, Helmut Fischer GmbH+Co.KG, Sindelfingen, Germany M. Haller, Fischer Technology, Windsor, CT

4:40 F-54 STARDUST COMETARY MATTER ANALYZED BY SYNCHROTRON NANO-XRF: NEW RESULTS AND DEVELOPMENTS T. Schoonjans, B. Vekemans, G. Silversmit, L. Vincze, Ghent University, Gent, Belgium

S. Schmitz, F. Brenker, Institut für Geowissenschaften, Frankfurt, Germany

5:00 F-64 L SHELL X-RAY FLUORESCENCE CROSS-SECTIONS FOR ELEMENTS WITH 33 ≤ Z ≤ 50 V. Sharma, N. Singh, S. Kumar, Panjab University, Chandigarh, India

XRD: High Resolution XRD FRIDAY A.M. PIKES PEAK 1 & 2

Chair: B. Tanner, University of Durham, Durham, United Kingdom

8:30 D-15 Invited— Laboratory-Based Characterization of Heteroepitaxial Structures: Advanced Experiments Not Needing Synchrotron Radiation

P. Zaumseil, IHP, Frankfurt, Germany

9:00 D-67 HIGH-RESOLUTION X-RAY DIFFRACTION DATA ANALYSIS FROM THE PARTLY RELAXED SEMICONDUCTOR STRUCTURES

A. Ulyanenkov, Bruker AXS GmbH, Karlsruhe, Germany

A. Benediktovitch, I. Feranchuk, Belarussian State University, Minsk, Belarus

B. He, H. Ress, Bruker AXS, Inc., Madison, WI

9:20 D-59 SPATIALLY RESOLVED DETERMINATION OF STRESS IN THIN FILMS AND DEVICES FROM CURVATURE MEASUREMENTS

N. Herres, Interstate University of Applied Sciences, Buchs, Switzerland

9:40 D-57 NIST SRM 2000—A HIGH RESOLUTION X-RAY DIFFRACTION STANDARD REFERENCE MATERIAL D. Windover, D.L. Gil, A. Henins, J.P. Cline, National Institute of Standards & Technology, Gaithersburg, MD

10:00 Break

- 10:20 D-89 INVITED—SIX WAYS OF DETERMINING FILM THICKNESS FROM HIGH RESOLUTION XRD DATA A.J. Ying, I.C. Noyan, Columbia University, New York, NY C.E. Murray, IBM T. J. Watson Research Laboratory, Yorktown Heights, NY
- 10:50 D-28 High-Resolution X-ray Scattering Methods for the Structural Characertization of Epitaxial Nitride Structures

J.F. Woitok, PANalytical B.V., Almelo, Netherlands

11:10 D-87 GRAZING INCIDENCE IN-PLANE X-RAY DIFFRACTION FROM EPITAXIAL FE/MGO/FE AND FE/AU/MGO/FE TUNNEL JUNCTIONS

D.S. Eastwood, M. Abes, B.K. Tanner, University of Durham, Durham, United Kingdom

T.P.A. Hase, University of Warwick, Coventry, United Kingdom

M. Ali, B.J. Hickey, University of Leeds, Leeds, United Kingdom

XRD: RIETVELD ANALYSIS FRIDAY A.M. CENTENNIAL

- Chairs: S.T. Misture, NYS College of Ceramics at Alfred University, Alfred, NY R.L. Snyder, Georgia Institute of Technology, Atlanta, GA
- 8:30 D-86 Invited—Structure Solution and Refinement Approaches for Oxide Ceramics S.T. Misture, Alfred University, Alfred, NY
- 9:00 D-54 CHARGE-FLIPPING STRUCTURE SOLUTION FROM SINGLE CRYSTAL AND POWDER DIFFRACTION DATA A. Kern, A.A. Coelho, Bruker AXS, Karlsruhe, Germany